



## OLED tools

... the atomistic part of  
our multiscale toolchain

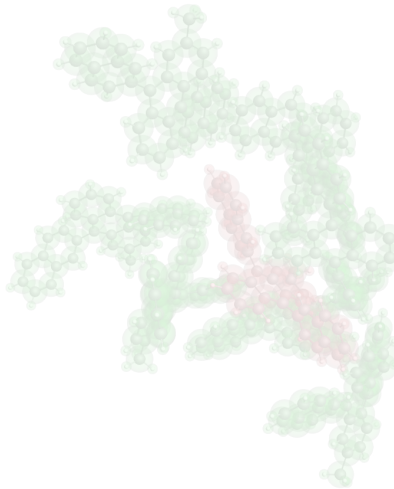
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Webinar | June 28th, 2023

## Two step process:

1 Deposition workflow

2 Properties workflow



# Deposition workflow

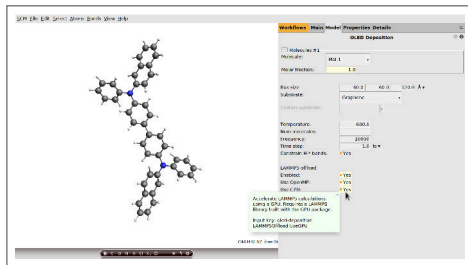
- Graphene sheet as starting substrate
- Molecules parameterized using UFF4MOF-II with CM5 charges
- Each molecule inserted 1 nm above surface (random xy position)
- After each insertion, 10k 1-fs MD steps followed by 10k fbMC steps to let molecule settle
- Periodic trimming to speed up simulation:
  - Molecules deep below surface frozen
  - Molecules below frozen layer removed
  - After reaching target thickness, all slices reassembled and whole box equilibrated under NpT, cooling down to room temperature



# Deposition workflow

New in AMS2023: LAMMPS/GPU offloading

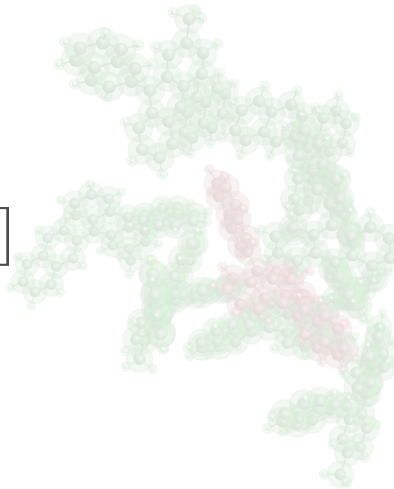
- Speedup of factor  $\approx 5$
- 2 weeks  $\Rightarrow$  3 days  
(standard box of 6x6x6 nm with approx. 500 molecules)



- requires user to compile LAMMPS
  - enabling GPU and OPENMP packages highly recommended
  - can work with CUDA or OpenCL, depending on how you configure LAMMPS
- communication between AMS driver and LAMMPS via AMSPipe protocol:  
[https://www.scm.com/doc/AMS/Pipe\\_protocol.html](https://www.scm.com/doc/AMS/Pipe_protocol.html)

# Deposition workflow

[Demo]



# Deposition workflow

[Video]

`downloads.scm.com/distr/OLEDTools_videos/deposition_  
mCP_1080p.mp4`

# Deposition workflow

Validation against thin-film densities

<b>Material</b>	$\rho_{\text{calc.}}$	$\rho_{\text{exp.}}^1$
BCP	1.148	$1.12 \pm 0.01$
CBP	1.184	$1.18 \pm 0.01$
$\alpha$ -NPB	1.114	$1.19 \pm 0.01$
$\alpha$ -MADN	1.142	...
mer-Alq3	1.272	$1.31 \pm 0.01$

Densities do not differ much between materials ...

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<sup>1</sup>Review of Scientific Instruments 78, 034104 (2007);  
<https://doi.org/10.1063/1.2712932>

# Properties workflow

- 1 For each molecule in the box:
  - Calculate atomic charges with cheap DFT: LDA/DZP with MDC-D charge model
- 2 For each molecule in the box:
  - Determine environment: any molecule within 15 Å (atom-atom distance)
  - For  $q \in \{-1, 0, +1\}$ :
    - Optimize geometry of central molecule in frozen environment: GFN1-xTB in UFF4MOF-II with electrostatic embedding
    - DFT single point on the optimized geometry: PBE/TZ2P (all-electron) with DRF environment
    - If  $q = 0$ : TD-DFT (PBE0) calculation for excitation energies.
  - Calculate (approximately adiabatic) IP and EA from total energy differences.
- 3 Transfer integrals for all dimers within 4 Å (atom-atom) distance of each other.

All default settings. Some things can be tweaked by the user ...



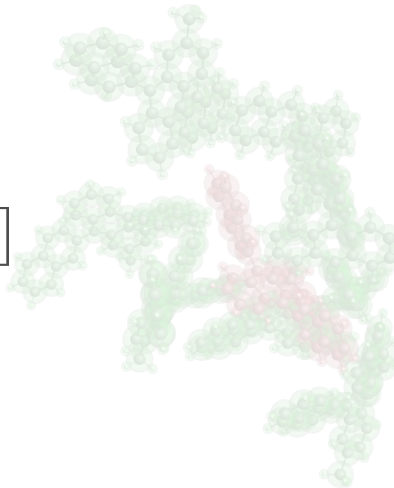
# Properties workflow

[Video]

`downloads.scm.com/distr/OLEDTools_videos/rotate_QMMM_`  
`mCP.mp4`

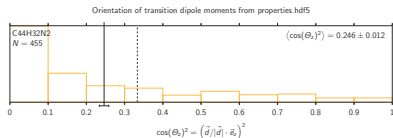
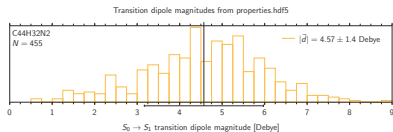
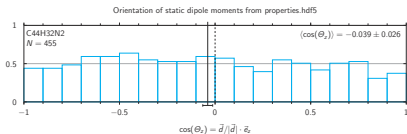
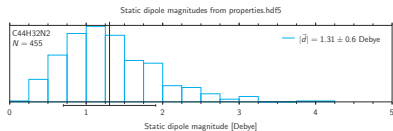
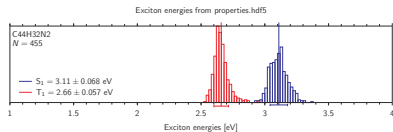
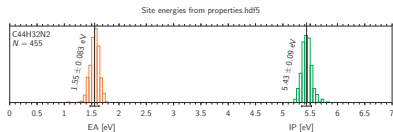
# Properties workflow

[Demo]



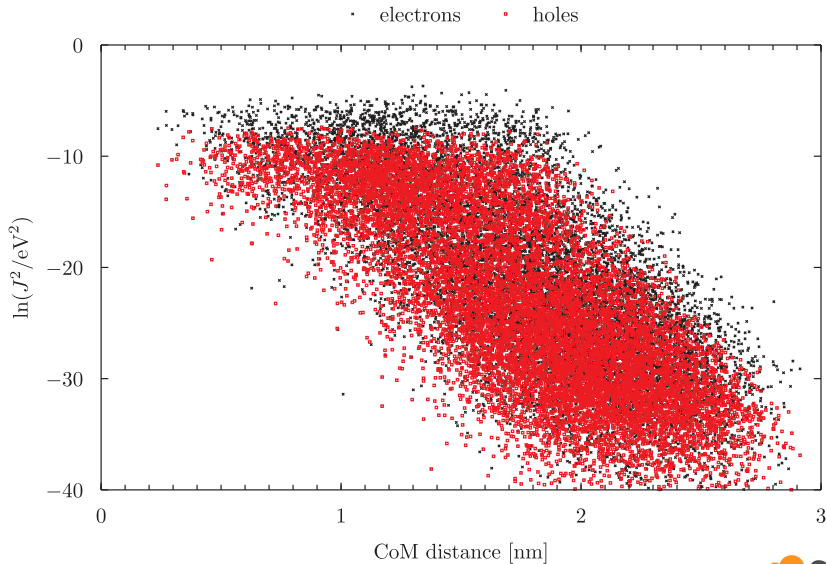
# Properties workflow

## Results for $\alpha$ -NPB: site energies and dipole moments



# Properties workflow

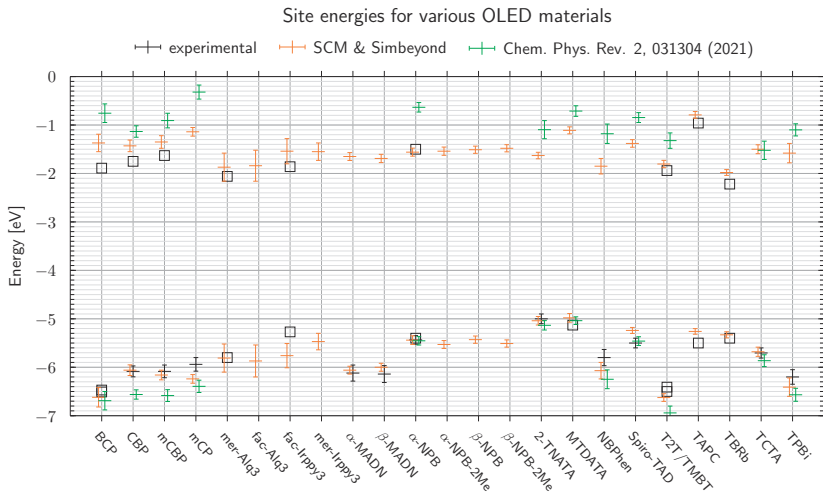
Results for  $\alpha$ -NPB: transfer integrals



# Properties workflow

Validation on IP/EA for standard materials

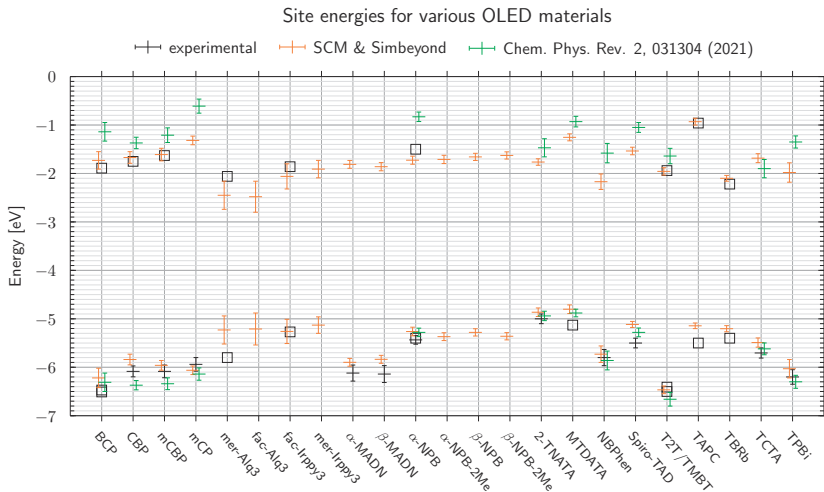
[distribution means]



# Properties workflow

Validation on IP/EA for standard materials

[IP/EA  $\pm 2\sigma$ ]



# Plans for AMS2024

## Further improvements for deposition workflow

- 1 whole-molecule moves in the force-bias Monte-Carlo part of the deposition:
  - increased mobility = better morphologies (?)
- 2 automated conformer handling for the deposited molecules:
  - currently we deposit a single conformer by default ..
  - ... whichever one the user puts into the input
  - no major conformational changes during MD in deposition
- 3 reduce protocol overhead in AMS ↔ LAMMPS communication
  - currently there is an inefficient Python glue-layer inbetween
  - can be done directly Fortran ↔ C++
  - expected speed-up of 3x ⇒ deposition in  $\approx 1$  day
- 4 re-deposit all standard materials for OLED material DB 2024

# Plans for AMS2024

## Further improvements for the properties workflow

- 1 GW/BSE for IP/EA and exciton energies
  - methods in AMS2023 already, but without support for DRF environment
  - equations have been derived by now, implementation in progress
- 2 more systematic validation of excitation energies
- 3 more properties: (non-)radiative decay rates, intersystem crossing rates, ...
- 4 increased range for transfer integrals
- 5 recalculate properties for all standard materials in OLED material DB 2024



# OLED workflows

[Tutorial]

[www.scm.com/doc/Tutorials/WorkflowsAndAutomation/OLEDMaterials.html](http://www.scm.com/doc/Tutorials/WorkflowsAndAutomation/OLEDMaterials.html)

[Manual]

[www.scm.com/doc/AMS/Utilities/OLEDWorkflows.html](http://www.scm.com/doc/AMS/Utilities/OLEDWorkflows.html)